



Idw/2812

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

ITOH ET AL.

Atty. Ref.: 1035-646

Serial No. 10/589,003

TC/A.U.: Unknown

Filed: August 10, 2006

Examiner: Unknown

For: GROUP I-VII SEMICONDUCTOR SINGLE CRYSTAL THIN FILM AND
PROCESS FOR PRODUCING SAME

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October 6, 2006

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

REQUEST FOR CORRECTED PTO-1449 FOR PREVIOUSLY FILED IDS

This corrected PTO-1449 for an IDS is submitted merely to correct the page number in the KAWAMORI et al. document that was incorrect in the previous IDS filed August 10, 2006. The minor correction made herein is that the page number of the above-referenced document was incorrectly stated as "pp.1915-1619" and should be inserted as "**pp.1615-1619**" on the PTO-1449. References are not provided herein, since they were submitted with the previous IDS. It is requested that the Examiner initial and return a copy of the corrected PTO-1449 attached hereto to the undersigned..

Respectfully submitted,

NIXON & VANDERHYE P.C.

By:

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**INFORMATION DISCLOSURE
CITATION**

 PATENT & TRADEMARK OFFICE
 U.S. DEPT. OF COMMERCE
 APPL. DOCKET NO.

1035-646

SERIAL NO.

10/589,003

OCT 06 2006

APPLICANT

ITO ET AL.

(Use several sheets if necessary)

FILING DATE

TC/A.U.

August 10, 2006

Unknown

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

DOCUMENT	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO

OTHER DOCUMENTS (including Author, Title, Date, Pertinent pages, etc.)

	KAWAMORI ET AL.; Growth of CuCl Nanostructure on CaF ₂ (111) Substrates by MBE-their Morphology and Optical Spectra; (2002), pp. 237-239 and pp. 1615-1619

*Examiner

Date Considered

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.